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PATENT APPLICATION

N THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Attn: OIPE

Yukio MIYAIRI et al.

Group Art Unit: 2624

Application No.: 10/562,467

Docket No.: 126464

Filed: December 27, 2005

For: PLASMA GENERATING ELECTRODE AND PLASMA REACTOR

REQUEST FOR CORRECTION OF PALM RECORDS

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

Attached is a photocopy of the original filing receipt on which errors have been corrected in red. These errors are being brought to the attention of the Patent and Trademark Office so that it may correct its records.

Respectfully submitted,

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JAO:RBI/rdb

Date: March 26, 2007

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2624

12/27/2005

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TOT CLAIMS

11

IND CLAIMS

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25944 OLIFF & BERRIDGE, PLC P.O. BOX 19928 **ALEXANDRIA, VA22320**

10/562,467

FILING RECEIPT

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Date Mailed: 01/25/2007

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Assignment For Published Patent Application

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Power of Attorney: The patent practitioners associated with Customer Number 25944

Domestic Priority data as claimed by applicant

This application is a 371 of PCT/JP04/09647 07/07/2004

Foreign Applications

JAPAN 2003-195165 07/10/2003

If Required, Foreign Filing License Granted: 04/04/2006

The country code and number of your priority application, to be used for filing abroad under the Paris Convention, is US10/562,467

Projected Publication Date: Not Applicable

Non-Publication Request: No

Early Publication Request: No

Title

Plasma generating electrode and plasma reactor

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